## IN THE SPECIFICATION ADD

BI	Before Line 1 on Page 1, please add:	"TITLE OF THE INVENTION"
Ba	Before Line 3 on Page 1, please add:	'BACKGROUND OF THE INVENTION'
გგ	Before Line 14 on Page 2, please add:	BRIEF SUMMARY OF THE INVENTION
	Before Line 34 on Page 5, please add:	BRIEF DESCRIPTION OF THE SEVERAL
B4		VIEWS OF THE DRAWINGS"
	Before Line 4 on Page 6, please add:	"DETAILED DESCRIPTION OF THE
Po		INVENTION"

## **IN THE SPECIFICATION AMEND**

Please delete the present abstract and insert instead:

-- "An optical arrangement, in particular a microlithographic projection printing installation, has in particular a slot-shaped image field or rotationally non-symmetrical illumination. An optical element (5) is therefore acted upon in a rotationally non-symmetrical manner by the radiation of a light source. To temper the optical element (5), a supply apparatus (11, 19 to 23) for gas is used. The latter having at least one supply line (21) and at least one gas directing device (11). The latter is aligned relative to the optical element (5) and controllable in such a way that the gas is directed by the gas directing device (11) towards the optical element (5). The volumetric flow of the exiting gas therefore has a magnitude and spatial distribution (17), which are adapted to the intensity distribution (6) of the radiation. By virtue of such tempering, rotationally non-symmetrical light-induced image defects in the optical element (5) are avoided or compensated." - -

